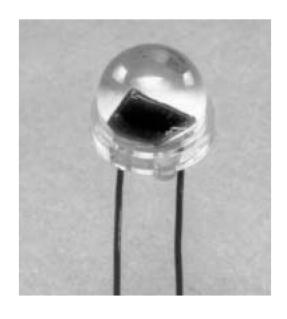
# **VTP Process Photodiodes**

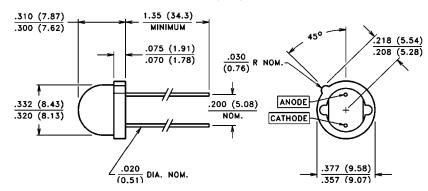
# **VTP1188SH**



### PRODUCT DESCRIPTION

Large area planar silicon photodiode mounted on a two lead ceramic substrate. A clear molded lens is used to increase sensitivity. Low junction capacitance permits fast response time.

### PACKAGE DIMENSIONS inch (mm)



CASE 12 LENSED CERAMIC CHIP ACTIVE AREA: .017 in<sup>2</sup> (11 mm<sup>2</sup>)

#### **ABSOLUTE MAXIMUM RATINGS**

Storage Temperature: -20°C to 75°C Operating Temperature: -20°C to 75°C

## **RoHS Compliant**



## ELECTRO-OPTICAL CHARACTERISTICS @ 25°C (See also VTP curves, pages 45-46)

| SYMBOL                 | CHARACTERISTIC                          | TEST CONDITIONS                 | VTP11188SH |      |      | UNITS |
|------------------------|---|---------------------------------|------------|------|------|-------|
|                        |   |                                 | Min.       | Тур. | Max. | UNITS |
| I <sub>SC</sub>        | Short Circuit Current                   | H = 100 fc, 2850 K              |            | 200  |      | μA    |
| TC I <sub>SC</sub>     | I <sub>SC</sub> Temperature Coefficient | 2850 K                          |            | .20  |      | %/°C  |
| I <sub>SC</sub>        | Short Circuit Current                   | 100 μW/cm <sup>2</sup> , 880 nm | 13         |      | 25   | μA    |
| V <sub>OC</sub>        | Open Circuit Voltage                    | H = 100 fc, 2850 K              |            | .33  |      | mV    |
| TC V <sub>OC</sub>     | V <sub>OC</sub> Temperature Coefficient | 2850 K                          |            | -2.0 |      | mV/°C |
| I <sub>D</sub>         | Dark Current                            | H = 0, VR = 10 mV               |            | 3    | 30   | nA    |
| R <sub>SH</sub>        | Shunt Resistance                        | H = 0, V = 10 mV                |            | 67   |      | GΩ    |
| TC R <sub>SH</sub>     | R <sub>SH</sub> Temperature Coefficient | H = 0, V = 10 mV                |            | -11  |      | %/°C  |
| СЈ                     | Junction Capacitance                    | H = 0, V =0 V                   |            | .18  | .30  | nF    |
| $\lambda_{ m range}$   | Spectral Application Range              |                                 | 400        |      | 1100 | nm    |
| $\lambda_{\mathrm{p}}$ | Spectral Response - Peak                |                                 |            | 925  |      | nm    |
| S <sub>R</sub>         | Sensitivity                             | @ Peak                          |            | .55  |      | A/W   |

# **VTP Process Photodiodes**

### VTP PROCESS FAST RESPONSE, HIGH DARK RESISTANCE

### **FEATURES**

- Visible to enhanced IR spectral range
- Integral visible rejection filters available
- Response @ 940 nm, 0.60 A/W, typical
- -1 to 2% linearity over 7 to 9 decades
- Low dark currents
- High shunt resistance
- High reverse voltage rating
- Low capacitance

### PRODUCT DESCRIPTION

Photodiodes in this series have been designed for low junction capacitance. The lower the capacitance, the faster the response of the diode. Also, speed can be further increased by reverse biasing the diodes which lowers the capacitance even more.

These diodes have excellent response in the IR region and are well matched to IR LEDs. Responsivity is categorized at 940 nm (GaAs LED). Some diodes are available in packages which incorporate a visible rejection filter effectively blocking any light below 700 nm.

Diodes made with the VTP process are suitable for operation under reverse bias conditions but may be used in the photovoltaic mode. Typical reverse breakdown voltages are around 140 V. Low dark currents under reverse bias are also a feature of this series.